

## Usage

- It will be used in PLD chamber
- The cleaning will be done by ultra sonication in IPA
- The deposition will be done at RT and 750 C for PLD
- It is quite stable at room temperature (the hazardous levels are very low as well) and its melting point is 2040 C
- Protective gears like hand gloves, face mask and safety goggles will be used while handling the substrate
- When not in use, it will be stored in evacuated desiccators